

<b>Notice of References Cited</b>	Application/Control No. 10/579,804	Applicant(s)/Patent Under Reexamination KAWAKAMI ET AL.	
	Examiner ANTHONY HO	Art Unit 2815	Page 1 of 1

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*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Name	Classification
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*	B	US-2003/0062520	04-2003	Toguchi et al.	257/40
*	C	US-2001/0025956	10-2001	Bohler et al.	257/40
*	D	US-2002/0034656	03-2002	Thompson et al.	428/690
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	K	US-			
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	M	US-			

**FOREIGN PATENT DOCUMENTS**

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**NON-PATENT DOCUMENTS**

*		Include as applicable: Author, Title Date, Publisher, Edition or Volume, Pertinent Pages)
	U	Danel et al, Chemical Materials, (2002), Vol. 14, p. 3860-3865
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\*A copy of this reference is not being furnished with this Office action. (See MPEP § 707.05(a).)  
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